

Semiconductor Wastewater Treatment Using Tapioca Starch as a Natural Coagulant

Mohd Omar Fatehah¹, Sohrab Hossain², Tjoon Tow Teng²

¹School of Civil Engineering, Universiti Sains Malaysia, Engineering Campus,
Seri Ampangan, Pulau Pinang, Malaysia

²Environmental Technology Division, School of Industrial Technology,
Universiti Sains Malaysia, Pulau Pinang, Malaysia
Email: fatehahomar@yahoo.com

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ABSTRACT

The efficiency of using tapioca starch as a natural coagulant on semiconductor wastewater treatment was investigated. The silica content in the wastewater was pH dependent and it was found that the reduction of COD and turbidity occurred at pH between 12 and 14 with measurements below 100 mg/L and 100 NTU respectively. A three-level factorial design experiment in the Response Surface Methodology (RSM) was applied to determine the influence of retention time and dosage of the tapioca starch. The parameters studied were chemical oxygen demand (COD), turbidity and total suspended solids (TSS). The R^2 for turbidity, COD and TSS were 0.92, 0.92 and 0.77 respectively. Results indicate that the dosage of the tapioca starch has a higher influence on COD and turbidity reduction. Tapioca starch as a natural coagulant has shown that the optimum turbidity reduction was 99% at a settling time of 30 minutes with dosage of 0.1 g/L. The COD reduction was achieved at 87% after 60 min of retention time and 0.1 g/L of dosage while higher coagulant dosages reduced the TSS concentration to 10.9 mg/L at retention time between 50 to 60 minutes.

Keywords: Chemical Oxygen Demand; Natural Coagulant; Response Surface Methodology; Semiconductor; Tapioca; Turbidity

1. Introduction

The semiconductor industry has emerged as one of the very important industries in Malaysia as well as in other countries [1-3]. Based on the Investment Performance Report in 2012 by the Malaysian Investment Development Authority (MIDA), the semiconductor sector has become one of the top eight new and emerging technologies in the manufacturing industries [4]. The semiconductor operation could account for as much as 40% of ultrapure water consumption in many highly complex and delicate processes that are involved in the factory [5,6]. This, in consequence, will generate equally large quantities of semiconductor wastewater from the final stage of washing and cleaning the wafer in the post-semiconductor processes.

Semiconductor wastewater is characterized as strongly dark in color, highly turbid, with high chemical oxygen demand (COD) concentration, low biodegradability, various solvents, acids, bases, salts, fine oxide particles and

may contain the presence of inorganic and organic contaminants. In general, inorganic contaminants may include suspended solids (in the range of nanometers to micrometers of SiO_2 , Al_2O_3 or CeO_2 with concentrations ranging from 50 to 500 mg/L whereas organic contaminants may include metal complexing agents, surfactants, stabilizers and rheology control agents [7-9]). Further detailed properties of semiconductor wastewater have been mentioned elsewhere [9-12]. Due to these characteristics, this low biodegradable wastewater can pose a considerable strain on the activated sludge in the biological wastewater treatment system and is not easily treatable with a single treatment approach [7,13].

Different treatment methods *i.e.* electrocoagulation [5, 9,14], air flotation [2,15], anaerobic degradation [6] have been applied to treat semiconductor wastewater. Other treatment such as membrane separation requires pre-coagulation because of the high concentration of Si in wastewater that can foul up the membrane and substantially

shorten its lifespan [16]. Chemical coagulation either inorganic (e.g. aluminum sulfate and polyaluminium chloride) or PAC, synthetic organic polymers (e.g. polyacrylamide derivatives) were also used to treat semiconductor wastewater [7,10,13,17,18]. Though other environmental friendly treatments have been applied to treat semiconductor wastewater [9], to the best of our knowledge, few studies on the application of natural coagulants as a substitute to inorganic chemical coagulants for the same purpose have been tried *i.e.* sago and potato starch [11]. However, other studies have reported on using natural materials as coagulants including *Moringa oleifera* [19-23], Nirmali seed and maize [24,25], mesquite bean and *Cactus latifaria* [26,27], *Cassia angustifolia* seed [28] and different leguminose species [29,30] to treat drinking water and wastewater generated from palm oil mill effluent (POME), paper mill, dyes and textiles. Natural coagulants have several advantages as they are available in abundance, cost-effective, environmental friendly, and biodegradable in nature [31].

In this study, subsequent to our previous studies [11, 32], we have applied tapioca starch as a natural coagulant to treat semiconductor wastewater. The objective was to investigate the effectiveness of tapioca starch as a natural coagulant to remove COD, turbidity and total suspended solids (TSS). The effects of the settling time were also investigated.

2. Materials and Methods

2.1. Coagulation Jar Test

The semiconductor wastewater was collected from a multinational semiconductor plant located in Bayan Lepas Industrial Zone, Penang, Malaysia. The samples collected were labeled and stored at 4°C for preservation. COD, TSS, pH and turbidity of the semiconductor wastewater were measured. The COD was determined using the spectrophotometer (Model-HACH, DR/2010) while turbidity (in terms of NTU) was determined using the turbidimeter (HACH-2100P). The TSS was calculated according to section 2540A and section 2540D [33]. The structure of silica particles in the semiconductor wastewater was observed at different magnifications using scanning electron microscope (SEM) image and energy dispersed X-ray spectrum (Model-JOEL).

The wastewater were adjusted to different pHs using the pH meter Model HACH sensION. Analytical grade NaOH pellets and HCl were used for pH adjustment. At each adjusted pH, the wastewater was allowed to settle over a period of 225 minutes where aliquots of the aqueous solution were extracted for COD, TSS and turbidity measured. Coagulation investigation was conducted using a jar test apparatus (JLT6, VELP, SCIENTIFICA) consisting of six 500 mL glass jars. Each jar was equip-

ped with a stirrer to rotate between 10 and 300 rpm. Tapioca flour was employed as the natural coagulant in the jar test. Five hundred milliliters of the raw silica wastewater were poured in each jar and the pH was adjusted to pH 12. The desired amount of coagulant was added with reference to the design of experiment in the response surface methodology (RSM). Then, the stirrer was turned on and set at 100 rpm with a mixing time of 5 minutes. The stirrer speed was then slowed to 10 rpm and continued mixing for another 15 minutes. The treated silica wastewater was finally allowed to settle according to the RSM design of experiment. Aliquots of the supernatant were extracted for COD, TSS and turbidity analysis.

2.2. Response Surface Methodology

A Three Level Factorial design in the RSM software was applied in the jar test coagulation study. In this study, the variables selected were retention time (minutes) as X_1 and dosage of coagulants (g/L) as X_2 . The responses observed were turbidity, COD and TSS. A second degree quadratic polynomial equation was used in Equation (1):

$$Y = B_0 + B_1X_1 + B_2X_2 + B_{12}X_1X_2 + B_{11}X_1^2 + B_{22}X_2^2 \quad (1)$$

where, Y is the predicted response, B is the linear coefficient, X_1 and X_2 are input variables (*viz.*, settling time and dosage). The low, middle and high levels of each variable, namely settling time and dosage, were coded as -1, 0, +1 respectively and given in **Table 1**. Based on Equation (1), a total of 13 runs were necessary in order to optimize the COD and turbidity removal that involved two independent variables, *viz.*, settling time and dosage. The design experiments were carried out using the software Design Expert (Courtesy: Stat-Ease Inc., Statistics Made Easy, Minneapolis, MN, USA. Version 6.0.10.2003).

3. Results and Discussion

3.1. Semiconductor Wastewater Characterization

Table 2 presents the semiconductor wastewater characteristics. The parameters determined were pH, temperature, total solids (TS), COD, TSS and turbidity.

The pH and turbidity values of the semiconductor wastewater were found to be pH 5.1 and 4246 NTU respectively whereas the COD and TSS concentrations were found at 1752 mg/L and 188 mg/L respectively, higher than the standard limits (100 mg/L) set by the Environmental Quality Act, 1974, Malaysia [34]. This generally reflects that the semiconductor wastewater contains contaminants in the waste slurry and small particulates such as suspensions of fine oxides (SiO_2 , Al_2O_3 , or CeO_2) and oxidizing agents (such as HNO_3 , $\text{Fe}(\text{NO}_3)_3$, etc.) from the wafer surface. **Figure 1(a)** shows the structure of the silica particles in the semi-

Table 1. The level of variables chosen for factorial design of analysis.

Retention Time, X_1	Dosage (g/L), X_2
0 (-1)	0.1 (-1)
30 (0)	0.55 (1)
60 (+1)	1.0 (+1)

Table 2. Characterization of semiconductor wastewater.

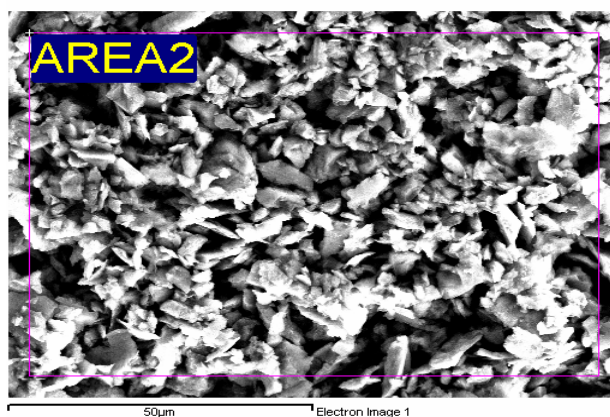
Parameter	Concentration	Unit
pH	5.1	-
Temperature	29	°C
Total Solids	0.14	mg/L
Chemical Oxygen Demand	1752	mg/L
Total Suspended Solids	188	mg/L
Turbidity	4246	NTU

conductor wastewater in the form of geometrical crystals. It was observed that the silica particles were stable and remained in suspension and dispersed like colloidal silica with a size distribution between 1 to 500 nm. **Figure 1(b)** displays the EDX spectrum band of the elemental composition of silica particles. From the spectrum band, it was determined that the particles were silicon dioxide (silica, SiO_2).

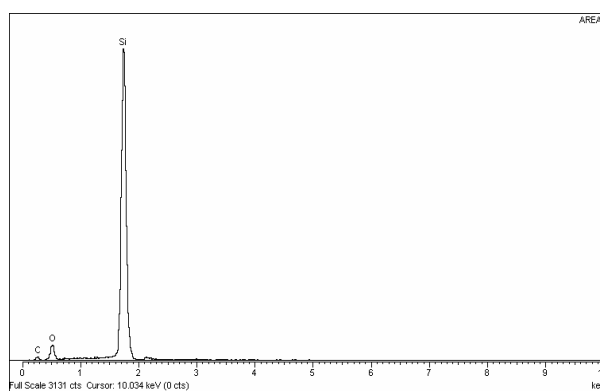
3.2. pH Effect on COD and Turbidity Reduction

Figure 2 represents the values of turbidity and COD at different pHs within the full pH range of 1 to 14 after one hour of settling time. The initial values of COD and turbidity at unadjusted pH were 1700 mg/L and 3800 NTU respectively. With reference to the z-axis that represents turbidity values, it was found that the turbidity concentration reduced when the pH was adjusted to both acidic and alkali conditions. The highest reduction was observed at 97% when the pH was between 12 and 14. At pH 10, the turbidity was about 100 NTU with a 73% reduction. For pH values between 3 and 9, the reduction of turbidity was insignificant. The reduction of turbidity might be due to the silica solubility which is observed to be highly influenced by pH. As the silica solubility increases, the turbidity of the wastewater decreases. Generally, silica forms Si(OH)_4 due to the dissolution with water. At lower pH levels between 1 and 3, the turbidity reduction could be due to the reaction of Si(OH)_4 with acid.

As the pH increases, the degree of ionization of Si(OH)_4 decreases, hence silica solubility decreases. However, the formation of silicate ion in addition to Si(OH)_4 in solution at higher pH regions (≥ 10) enhances



(a)



(b)

Figure 1. (a) SEM image of silica particles and (b) Energy dispersive X-ray (EDX) spectrum in raw semiconductor wastewater. It was observed that the silica particles were in the form of geometrical crystals which remained in suspension and dispersed.

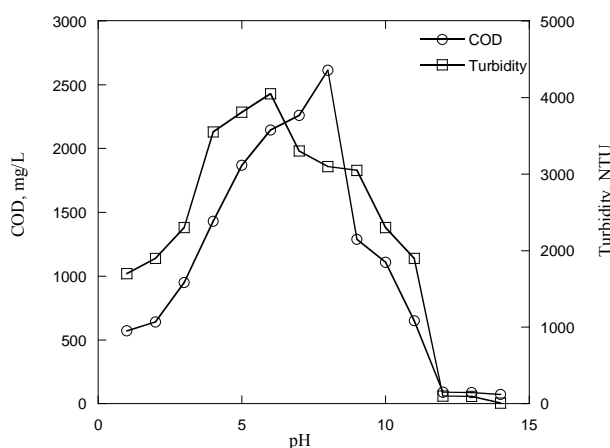


Figure 2. COD and turbidity concentration profiles with a function of pH within 1 hour of settling time.

the silica solubility, which significantly reduces the turbidity of wastewater [35].

On the y-axis that represents the COD concentration, it

was found to decrease at higher acidic and alkaline conditions, at ranges of pH 1 - 3 and pH 12 - 14, respectively. At pH 1, the COD concentration was about 570 mg/L. It was observed that COD concentration increased with increasing inducing pH of the semiconductor wastewater up to pH 8. The reduction of COD concentration might be due to the silica solubility in semiconductor wastewater, as the silica solubility increased, the COD concentration decreased in the semiconductor wastewater. It was observed during the pH adjustment that the fine suspended silica particles seemed to dissolve and disappear at higher alkaline pH region. It is reported that the silica solubility in the semiconductor wastewater increases proportionately with increasing the alkaline pH [35]. However, COD concentration was found higher compared to initial COD concentration of semiconductor wastewater, which could be due to the release of the outer layer of the silica particles which remained as un-settleable particles into the solution.

In **Figure 3**, the reduction of COD concentration was observed within a pH range of 1 and 4 at different retention times. For pH 1 and 2, it was observed that the COD concentrations reduced to about 600 and 700 mg/L almost instantly at minute-0, respectively. At the same pHs, with longer retention of 200 minutes, the lowest COD concentration of about 200 mg/L was obtained. In the case of pH 3 and 4, the COD concentration decreased to about 900 and 1400 mg/L at minute-0, respectively. In compare to the pH ranges above, pH 12 was finally determined as the optimum pH for further investigation.

3.3. Removal of COD, Turbidity and TSS with Tapioca Starch

Figure 4(a) shows the SEM image of the wastewater sludge from tapioca starch. The tapioca starches are made of spherical granules, having a 5 to 35 μm diameter, compact with small spaces between the particles. This is

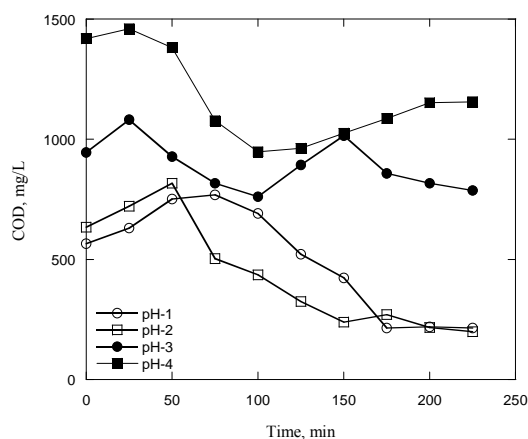
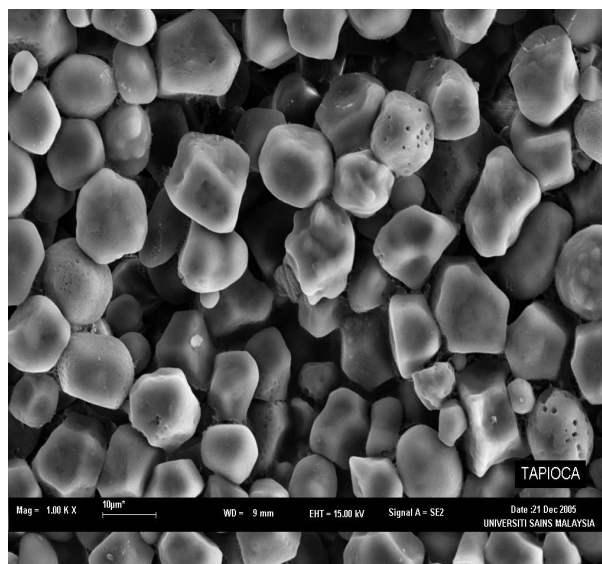
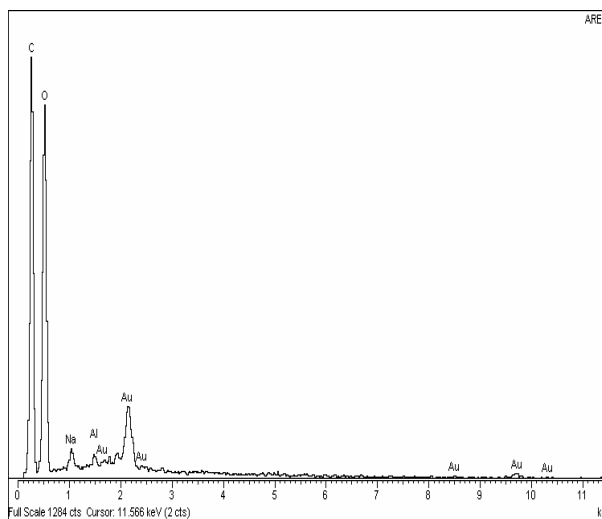


Figure 3. COD profile concentration at pH 1 to 4 with a function of time (minutes).



(a)



(b)

Figure 4. (a) SEM image of the surface of the sludge using tapioca starch (b) EDX analysis of the tapioca-silica sludge.

in agreement with other studies which state that the structure of [36] tapioca starch granules is truncated, round or oval with a measurement of 15 μm in diameter. In **Figure 4(b)**, the EDX spectrum of the tapioca starch shows the presence of sodium and aluminium. Starches contain relatively small quantities (<0.4%) of minerals (calcium, magnesium, phosphorus, potassium and sodium) which are, with the exception of phosphorus, of little functional significance. Tapioca starch is less starchy due to the lower presence of lipid and proteins and has a higher degree of polymerization of amylose molecules than maize and wheat starch. Tapioca starch also has higher solubilization compared to cereal starch and is less stringy and cohesive compared to potato starch as well as being translucent, clear and transparent [36].

3.3.1. Turbidity Removal

The turbidity reduction in the semiconductor wastewater with different coagulant concentrations and settling times is shown in **Table 3**. The initial turbidity was 2200 NTU. At low coagulant dosages with long settling times the turbidity concentration decreased significantly. However, the optimum turbidity reduction was about 99% with a settling time of 30 minutes using 0.1 g/L of tapioca starch.

The turbidity successfully reduced to 51.62 NTU, achieving 98.0% reduction using 0.1 - 0.33 g/L of dosage and retention time between 30 - 60 minutes. However, it was observed that with increasing dosages of tapioca starch, the turbidity reduction decreases. The optimum turbidity reduction was achieved at 0.1 g/L and retention time of 30 minutes. The R^2 was 0.922 and the model was described using a second order quadratic model on the reduction of turbidity can be represented by following equation:

$$Y_{TURB} = 128.93 - 6.43X_1 + 247.98X_2 + 0.07X_1^2 - 100.03X_2^2 - 0.25X_1X_2 \quad (2)$$

Figure 5(b) represents the close to fit in the experimental values with the predicted data on turbidity reduction in semiconductor wastewater. From Equation (1), the accuracy of prediction was 92% and the contributing factor was mainly the coagulant dosage. Hence, the effect of the tapioca starch concentration on turbidity reduction was prominent. The value of the turbidity could be predicted based on the controlled values of the independent variables of dosage and settling time up to an accuracy of 92%. **Table 4** shows the analysis of variance with the Model F-value of 16.52 that implies the model was significant and according to the ANOVA interpretation. There was only 0.09% chance that a “Model F-value” this large could occur due to interference. Further, the ANOVA interpretation, indicated that the “Prob > F” is 0.0009 and accordingly, values of “Prob > F” less than 0.05 indicate model terms X_1 , X_2 and X_1^2 were significant.

Table 3. The reduction of turbidity on settling time using tapioca starch.

Settling time (eminut)	Tapioca Starch (g/L)		
	0.1	0.55	1.0
	Turbidity NTU (Initial turbidity: 2200 NTU)		
0	147.6	223.2	293.9
30	21.7	115.6	94.7
60	28.6	62	161.3

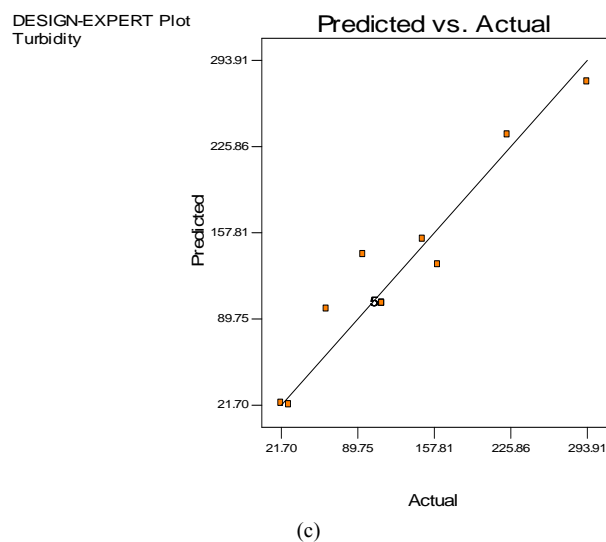
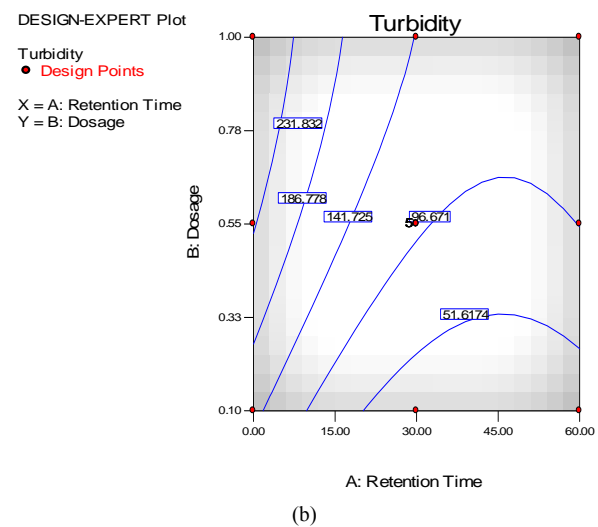
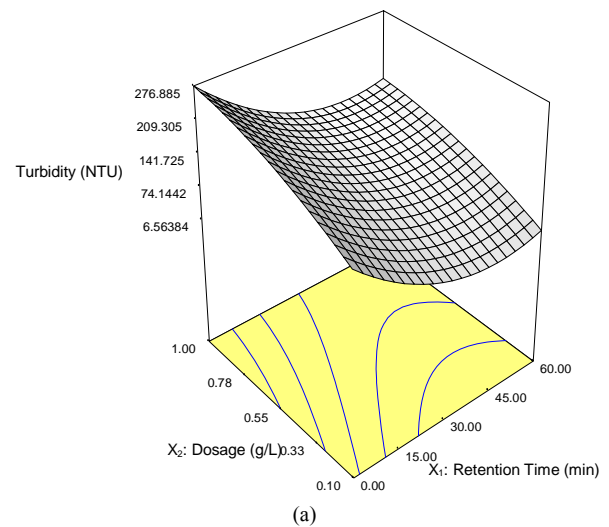


Figure 5. Reduction of turbidity in semiconductor wastewater using tapioca starch as function of retention time. (a), Surface plot and (b), contour plot; (c) Predicted vs. actual values.

3.3.2. COD Removal

The COD reduction using tapioca starch with varying settling time is depicted in **Table 5**. Data show that the highest COD removal was achieved at 87% with a settling time of 60 min using 0.1 g/L of tapioca starch. However, the COD removal found to decrease the dosages of the tapioca starch increased. **Figure 6** shows the three dimensional response surface and contour plots on the removal of COD using tapioca starch as a natural coagulant. As can be seen on the surface plot (**Figure 6(a)**), the COD value reduces at 256.24 mg/L using tapioca starch dosage range of 0.1 to 0.6 g/L at retention time between 20 to 60 minutes. However, the measurable difference COD reduction was obtained at the tapioca starch dosage of 0.55 g/L, the COD value started off at 374 mg/L, subsequently fall down to 353.22 mg/L at retention time of 17 minutes, 304.7 mg/L at 40 minutes and eventually to 256.2 mg/L at retention time of 60 minutes. **Figure 6(c)** shows the predicted vs. actual values on measurement in semiconductor wastewater using tapioca starch as a natural coagulant. It is found that most of the points are located quite close to the line giving an impression of closeness of fit and if judged from the regression coefficient.

The proposed model was adequate, possessing no significant lack of fit and very satisfactory value of R^2 at 0.919 of 91.9% accurate. The closer the R^2 value to unity, the better the empirical formula fits the actual data. The regression analysis is meant to predict the value of a dependent variable based on the controlled values of inde-

Table 4. Analysis of variance for turbidity after addition of tapioca starch during the coagulation treatment of semiconductor wastewater.

Source	Sum of Squares	DF	Mean Square	F Value (Prob > F = 0.0009)
Model	60504.2	5	12100.84	16.52
Residual	5128.87	7	732.70	
Cor Total	65633.08	12		

Table 5. COD of the semiconductor wastewater after tapioca starch treatment at various dosages and retention time.

Retention time (t = minutes)	Dosage (g/L)		
	0.1	0.55	1.0
	COD (mg/L) (initial COD: 1130 mg/L)		
0	274.86	374.91	466.6
30	255.65	300.34	353.38
60	149.22	234.55	311.53

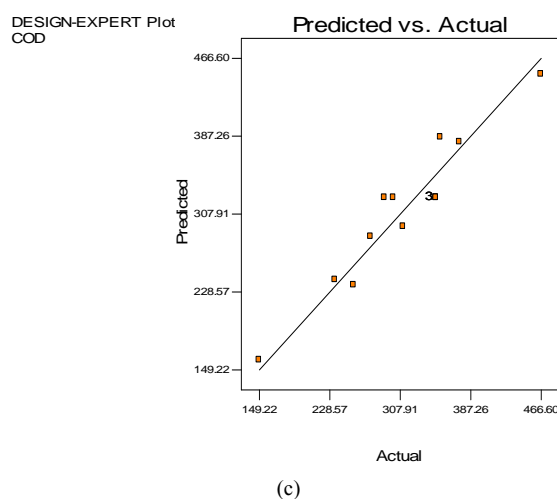
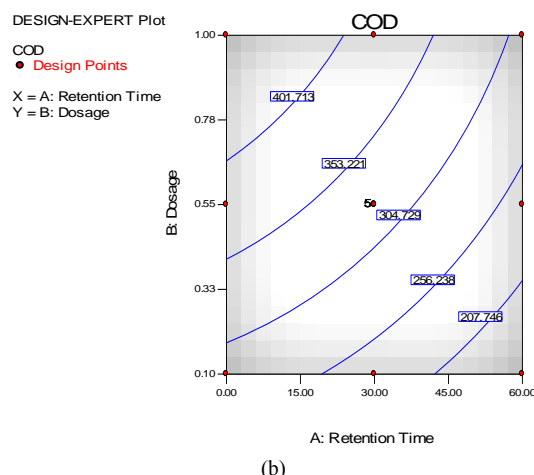
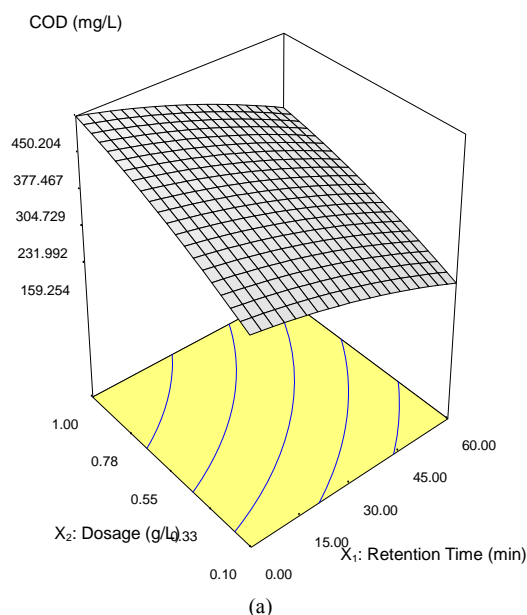


Figure 6. COD removal using tapioca starch as a natural coagulant with dosage ranging from 0.1 to 1.0 g/L and at retention time from 0 to 60 minutes (a) Surface plot, (b) contour plot, (c) Predicted vs. actual values.

pendent variables. The R^2 was 0.919 and the model description used was a second order quadratic model represented by following equation:

$$Y_{COD} = 259.75 - 1.13X_1 + 258.20X_2 - 0.02X_1^2 - 67.75X_2^2 - 0.545X_1X_2 \quad (3)$$

Based on the Equation (3), the COD removal was highly depended on the dosages rather than retention time. The analysis of variance of COD removal in semiconductor wastewater using the tapioca starch as a natural coagulant is given in **Table 6**. The “Model F-value” of 15.93 implies the model is significant. From the ANOVA, there was only a 0.11% chance that a “Model F-value” could be due to interference. Value of Prob > F in this case is 0.011 and is less than 0.05 which indicates that the model terms X_1 and X_2 are significant.

3.3.3. TSS Removal

Table 7 shows the TSS concentration of the semiconductor wastewater using tapioca starch at various retention times. It is found that the TSS concentration increased considerably from the initial concentration of 73.7 mg/L with the addition of tapioca starch.

However, the TSS concentration found to be reduced immensely with dosages 0.55 g/L and 1.0 g/L at retention time of 0 and 30 minutes, respectively. The sudden increase indicated that starch particles remained suspended for a period of time before it eventually settled out. **Figure 7** shows the surface and contour plots of the TSS removal using tapioca starch with a function of retention time. Employing higher dosages, between 0.8 to 1.0 g/L,

Table 6. Analysis of variance on COD removal using tapioca starch during coagulation treatment of semiconductor wastewater.

Source	Sum of Squares	DF	Mean Square	F Value
Model	65437.38	5	13087.48	15.93
Residual	5751.40	7	821.63	
Cor Total	71188.77	12		

Table 7. Removal of TSS of the semiconductor wastewater after tapioca starch treatment at various dosages and retention times.

Retention time (t = minutes)	Dosage (g/L)		
	0.1	0.55	1.0
	Total suspended solids (mg/L) (initial TSS: 73.7 mg/L)		
0	295.66	476.93	817.53
30	246.55	392.03	12.99
60	181.73	11.62	11.47

reduced the TSS concentration to 10.9 mg/L at retention time between 50 to 60 minutes. However, TSS removal was 564.3 mg/L at retention about 7 minutes, 10.8 mg/L at retention time of 50 minutes using 1.0 g/L tapioca starch. In contrast, using 0.55 g/L tapioca starch the TSS concentration is 425.9 mg/L at 20 minute retention time, was reduced to 149.2 mg/L at 60 minutes retention time. The model description representing the TSS analysis is a second order quadratic model equation as shown in Equation (4). The coefficient of determination, R^2 was 0.768, indicating the accuracy about 78%.

$$Y_{TSS} = 187.85 - 2.35X_1 + 1039.45X_2 + 0.05X_1^2 - 524.59X_2^2 - 14.20X_1X_2 \quad (4)$$

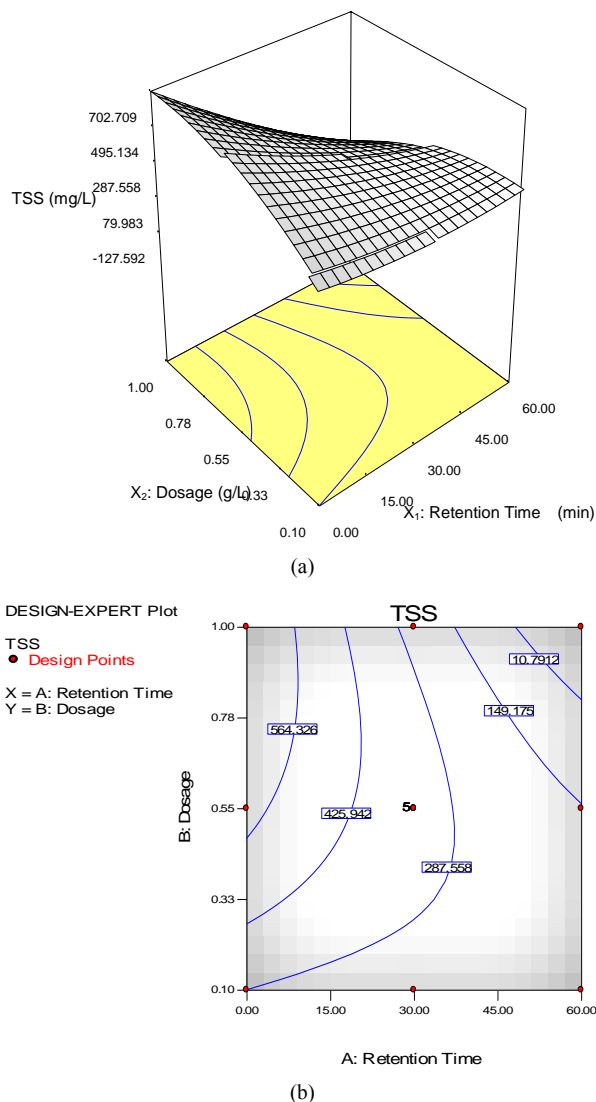


Figure 7. Surface (a) and contour (b) plots on TSS removal from semiconductor wastewater using tapioca starch as natural coagulant with dosage ranging from 0.1 to 1.0 g/l and retention time from 0 to 60 minutes.

Table 8. Analysis of variance for TSS reduction after addition of tapioca starch during the coagulation treatment of semiconductor wastewater.

Source	Sum of Squares	DF	Mean Square	F Value (Prob >F = 0.0347)
Model	4.793E + 005	5	95860.82	4.63
Residual	1.449E + 005	7	20694.76	
Cor Total	6.242E + 005	12		

The Model F-value for the analysis of variance indicated a value of 4.63, as presented in **Table 8**. From the interpretation of the analysis, there was only a 3.47% chance that a “Model F-value” this large could occur due to interference. The Prob > F value is 0.0347 which is less than 0.05 and this demonstrates that the model terms were significant. In this case, X_1 , and X_1X_2 were significant model terms.

4. Conclusion

Treatment of semiconductor wastewater from a multinational semiconductor manufacturer was investigated using tapioca starch as a natural coagulant. The characteristics of the semiconductor wastewater were determined with TSS at 188 mg/L, turbidity at 4246 NTU and COD at 1752 mg/L. The silica solubility in the wastewater was pH dependent. Turbidity reduction was achieved with the highest value of about 97% whereas the COD concentration was found below 100 mg/L within the pH range 12 - 14. Tapioca starch as a natural coagulant has shown that the optimum turbidity reduction was 99% at a settling time of 30 minutes with dosage of 0.1 g/L. The COD reduction was achieved at 87% after 60 min of retention time and 0.1 g/L of dosage. With higher coagulant dosages, the TSS concentration reduced to 10.9 mg/L at retention time between 50 to 60 minutes. Overall, the findings were significant with R^2 for turbidity, COD and TSS were 0.92, 0.92 and 0.77 respectively.

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